with an electrocyclic ring opening to 7 which gives rise to 4, 5, and 6 (Scheme I). All the observed products are readily accomodated by these two mechanisms.

Acknowledgment. We thank the National Science Foundation, the National Institutes of Health (CA 23488), and the donors of the Petroleum Research Fund, administered by the American Chemical Society, for financial support.

Registry No. 1, 65754-71-4; **2**, 2327-56-2; **2** TCNE adduct, 80485-39-8; **3**, 1961-93-9; **3** TCNE adduct, 80502-01-8; **4**, 68367-49-7; **5**, 90-12-0; **6**, 91-57-6; **11**, 276-32-4; **13**, 264-08-4; bicyclo[6.3.0]undeca-1-(8),2,4,6,9-pentaene, 276-33-5.

Silylene to Silene Thermal Rearrangement. Generation and Rearrangement of Cyclopropylsilylene and Vinylsilylene

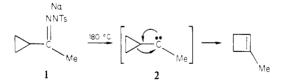
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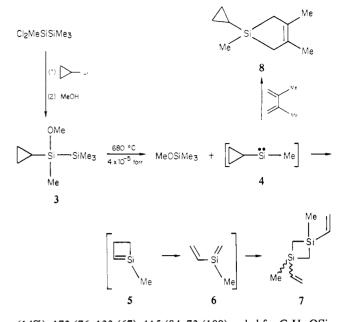
Received October 26, 1981

Although the isomerization of carbenes to olefins is a longestablished reaction and there are now several documented examples of facile rearrangement of silylcarbenes to silenes $(R_2Si=CR'_2)$,¹ there exists only a single report² of the rearrangement of a silylene $(R_2Si:)$ to a silene.³ Thus, the photochemically induced isomerization of Me₂Si: to MeHSi=CH₂² is the sole example of a reaction which recent calculations reveal to be essentially thermoneutral.⁶

In an attempt to gain the first definitive evidence for a thermally induced silylene to silene rearrangement, it was decided to generate cyclopropylmethylsilylene (4), as thermally generated cyclopropylcarbene (2) is known to undergo facile rearrangement via ring expansion. For example, thermolysis of the sodium salt of cyclopropyl methyl ketone tosylhydrazone (1) affords 1methylcyclobutene in 92% yield.⁷



Synthesis of the desired thermal precursor of silylene 4 was accomplished by reaction of 1,1-dichlorotetramethyldisilane and cyclopropyllithium⁸ (Et₂O, 0 °C, 160 min) followed by quenching with an equimolar mixture of methanol and pyridine. After distillation [72–75 °C (20 torr)], separation of 1-cyclopropyl-1-methoxytetramethyldisilane (3) from 1,1-dicyclopropyltetramethyldisilane was achieved by preparative gas chromatography (GC) [3: 30% yield; NMR (CCl₄) δ 0.00 (s, 3H), 0.10 (s, 9H), -0.40 to 0.70 (m, 5H), 3.38 (s, 3H); mass spectrum, m/e 188

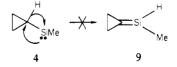


(14%), 173 (76, 133 (67), 115 (84, 73 (100); calcd for $C_8H_{20}OSi_2$ *m/e* 188.1053, measured *m/e* 188.1055; 30% yield]. Flash vacuum pyrolysis (FVP) of **3** was conducted through a quartzpacked horizontal 36-cm tube at 680 °C (4 × 10⁻⁵ torr) with 88% mass balance. The two major products were isolated by preparative GC: trimethylmethoxysilane (99%) and 1,3-dimethyl-1,3-divinyl-1,3-disilacyclobutane (7) (42%) as an equal mixture of cis and trans isomers [7, NMR (CCl₄) δ 0.14 (apparent t, 4H), 0.28 (s, 3H), 0.30 (s, 3H), 5.35–6.57 (vinyl m, 6H); mass spectrum, *m/e* 168 (24%), 153 (64), 140 (100), 127 (68), 126 (20), 125 (64), 113 (46), 99 (41), 85 (30), 83 (18), 73 (27), 71 (31), 69 (27), 59 (65); calcd for C₈H₁₆Si₂*m/e* 168.0788, measured *m/e* 168.0791].

The most economical mechanistic rationalization for the formation of 7 is α elimination of Me₃SiOMe to form silylene 4, ring expansion of 4 to 1-methyl-1-silacyclobutene (5), ring opening of 5 to vinylsilene 6, and the usual head-to-tail silene dimerization of 6. Thus, the conversion of 4 to 5 represents the first example of a thermal silylene to silene rearrangement. Also, the isomerization of 5 to 6 represents the first example of a silene to silene rearrangement.

Evidence that silylene **4** is indeed involved in this remarkably efficient sequence was obtained from the cothermolysis of **3** and 2,3-dimethylbutadiene (500 °C, vertical quartz-packed 36-cm tube, 55-mL/min N₂ flow) to afford 4-cyclopropyl-1,2,4-trimethyl-4-silacyclopentene (**8**), the expected product of addition of **4** to the diene [**8**: 43% yield; NMR (CCl₄) δ -0.44 to 0.70 (m, 5H), 0.07 (s, 3H), 1.20 (br s, 4H), 1.63 (br s, 6H); mass spectrum, m/e 166 (56%), 151 (23), 125 (100), 124 (83), 123 (77), 109 (90), 97 (31), 95 (26), 85 (28), 83 (45), 69 (42), 67 (22), 59 (96), 58 (28); calcd for C₁₀H₁₈Si m/e 166.1178, measured m/e 166.1179].

It is of interest to note that silylene 4 eschews the opportunity for 1,2-hydrogen migration to silicon to form cyclopropylidenesilane 9. Molecular orbital calculations have revealed that the



silicon-carbon double bond should be significantly strengthened by $d-\sigma$ hyperconjugation in the silicon analogue of methylenecyclopropane.⁹

Another carbene that is known to undergo facile rearrangement is vinylcarbene which isomerizes to cyclopropene through intramolecular π addition.¹⁰ Thus, we constructed 1-chloro-1-

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⁽³⁾ Gaspar⁴ has made the interesting suggestion that the origin of 1,3dimethyl-1,3-disilacyclobutane from generation of Me₂Si: above 600 °C could "in principle" arise from Me₂Si: rearranging to MeHSi=CH₂ followed by dimerization. However, this mechanism is not demanded.⁵

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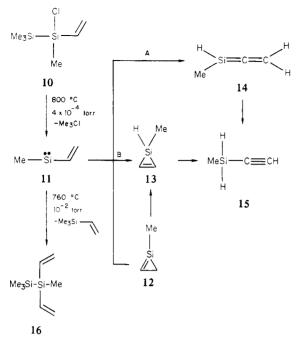
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vinyltetramethyldisilane (10) by reaction of 1,1-dichlorotetra-



methyldisilane and 1 equiv of vinylmagnesium chloride in THF [10: 42% by NMR, 17% GC isolated; NMR δ 0.17 (s, 9H), 0.5 (s, 3H), 6.08 (m, 3H); mass spectrum, m/e 180 (0.9%), 178 (2.4), 165 (2.2), 163 (4.6), 155 (38), 85 (69), 73 (1 00); calcd for $C_6H_{15}Si_2Cl m/e 178.0401$, measured m/e 178.0401].

FVP of 10 [800 °C 4 \times 10⁻⁴ torr)] afforded two products of α elimination, trimethylchlorosilane (30%) and trimethylvinylsilane (11.5%), along with a surprising third major product, ethynylmethylsilane [15: 11.9% (39% based on Me₃SiCl); NMR of SiMe obscured by impurity absorbtions, δ 2.27 (t, 1H, J = 1 Hz, collapses to s with $h\nu$ at δ 4.05, C=CH), 4.05 (d of q, 2H, J = 4.5 and 1 Hz, $h\nu$ at δ 2.27 collapses to q; mass spectrum, m/e 70 (27%), 69 (24), 68 (7), 55 (100), 54 (17), 53 (42); both NMR and mass spectrum matched those of an authentic sample of 15 prepared from LAH reduction of dichloroethynylsilane]. Ethynylsilane (15) was also observed (by NMR spectrometry among the products from the FVP [760 °C (10⁻² torr)] of 1,1-divinyltetramethyldisilane (16). The major product of this pyrolysis is trimethyl vinylsilane arising from α elimination to afford vinylsilvlene 11. Thus, it seems likely that ethynylsilane (15) arises from isomerization of silylene 11. It is reasonable to suggest that the isomerization is initiated by intramolecular π addition to form 1-silacyclopropene 12 (the known carbene mechanism)¹⁰ followed by (disallowed) hydrogen migration to silicon.

Indeed, the formation of silvlacetylenes from the gas-phase copyrolyses of silylene precursors and terminal acetylenes has previously been argued to involve rearrangement of intermediate silacyclopropenes.^{4,11} Two other routes are possible: (A) α -C-H insertion to form silaallene 14 followed by 1,3-hydrogen migration; (B) β -C-H insertion to directly form silirene 13. Neither of these paths has ever been observed for vinylcarbenes.¹² Thus, it is likely, but not demanded, that the isomerization of 11 to 15 involves the intermediacy of silirene 12 and represents another silvlene to silene rearrangement. Labeling experiments and alternant methods for generation of 11 must now be performed to clear up the admittedly speculative route for the 11 to 15 isomerization.

Currently we are attempting extensions of these rearrangements, including the obvious cyclopropenylsilylene to silacyclobutadiene isomerization.

Acknowledgment. The support of this research by the National Science Foundation is gratefully acknowledged.

Registry No. 1, 80631-65-8; 3, 80631-66-9; 5, 80631-67-0; 6, 80631-68-1; cis-7, 74045-33-3; trans-7, 74045-45-7; 8, 80631-69-2; 10, 80631-70-5; 12, 80631-71-6; 15, 16689-89-7; 16, 70745-07-2; 1-methylcyclobutene, 1489-60-7; 1,1-dichlorotetramethyldisilane, 4518-99-4; trimethylmethoxysilane, 1825-61-2; cyclopropyllithium, 3002-94-6; 2,3dimethylbutadiene, 513-81-5; vinyl chloride, 75-01-4; trimethylchlorosilane, 75-77-4; trimethylvinylsilane, 754-05-2.

Cyclotrisilane (R₂Si)₃ and Disilene (R₂Si=SiR₂) Systems: Synthesis and Characterization

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> > Received December 7, 1981

Recent renewed activities in cyclopolysilane chemistry¹ concern the nature of silicon-silicon bonding in small ring systems.^{1,2} Thus, the degree of electron delocalization in the yet unknown cyclotrisilane (trisilacyclopropane) system (1) attracts special interest.³ Its physical and chemical properties would be unique in many ways. While a large number of cyclopolysilanes (CR₂Si), with $n \ge 4$ are available through the reaction of a dichlorosilane with an appropriate electron donor,^{1,4} the thus far unsuccessful construction of this smallest ring system has been attributed (tacitly) to the expected high instability and/or reactivity owing to the ring strain intrinsic to $1.^5$ Apparently, the careful selection of both the silicon substituents (R's) and the electron donor is of vital importance in the synthesis. Using an approach similar, in principle, to that adopted earlier in the synthesis of an isolable cyclobutadiene derivative,⁶ we have now achieved the first synthesis of a crystalline derivative, hexa-2,6-dimethylphenylcyclotrisilane (1a). We present herein not only unequivocal evidence for the structure of this new compound, but also we describe its remarkable reaction, a near-quantitative photochemical conversion into the corresponding disilene (Si=Si) derivative (2),^{7,8} yet an-

(1) For the synthesis of peralkylpolycyclosilanes, see: (a) Watanabe, H.; Muraoka, T.; Kageyama, M.; Nagai, Y. J. Organomet. Chem. 1981, 216, C45 (b) Watanabe, H.; Muraoka, T.; Kohara, Y.; Nagai, Y. Chem. Lett. **1980**, 735. (c) Carlson, C. W.; Matsumura, K.; West, R. J. Organomet. Chem. **1980**, 194, C5. (d) Biernbaum, M.; West, R. Ibid. **1977**, 131, 179 and references quoted therein. (e) For a review of perarylpolycyclosilanes, see: Gilman, H.; Schwebke, G. L. Adv. Organomet. Chem. 1964, 1, 89.

(2) For the properties of peralkylpolycyclosilanes, see: (a) West, R.; Carberry, E.; Science 1975, 189, 179. (b) Brough, L. F.; West, R. J. Organomet. Chem. 1980, 194, 139 and the preceding articles of this series.

(3) The system is mentioned from time to time in the literature. For instance, see: Ishikawa, M.; Kumada, M. Adv. Organomet. Chem. 1981, 19, 51

(4) The method was originated by: Kipping, F. S. Proc. Chem. Soc. 1911, 27, 143.

(5) Even cyclotetrasilanes $(R_2Si)_4$ react readily with oxygen if the substituents are small, e.g., R = CH₃. See: Ishikawa, M.; Kumada, M. J. Organomet. Chem. 1972, 42, 325.

(6) (a) Masamune, S.; Nakamura, N.; Suda, M. Ona, H. J. Am. Chem. Soc. 1973, 95, 8481. (b) Delbaere, L. T. J.; James, M. N. G.; Nakamura, N.; Masamune, S. Ibid. 1975, 97, 1973. (c) Bally, T.; Masamune, S. Tetrahedron 1980, 36, 343.

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⁽¹²⁾ See ref 10. The π -addition mechanism is obvious from the fact that cyclopropenes are best formed from β , β -disubstituted vinylcarbenes.

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